

INTERNATIONAL
GEMOLOGICAL
INSTITUTE

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LABORATORY GROWN DIAMOND REPORT

December 11, 2025

IGI Report Number

Description

Shape and Cutting Style

Measurements

LG756541577

LABORATORY GROWN DIAMOND

OVAL BRILLIANT

10.91 X 7.73 X 4.68 MM

GRADING RESULTS

Carat Weight

Color Grade

Clarity Grade

2.51 CARATS

F

VS 1

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence


EXCELLENT

EXCELLENT

NONE

Inscription(s)

Comments: This Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

 LG756541577

PROPORTIONS

Medium To Slightly Thick (Faceted)

Diagram of an oval brilliant diamond with proportions: 62% (table), 13% (depth), 43.5% (height), 60.5% (width), and Pointed (tip).

CLARITY CHARACTERISTICS

Diagram 1: Top view of the diamond showing internal characteristics (red symbols) and external characteristics (green symbols).


Diagram 2: Side view of the diamond showing internal characteristics (red symbols) and external characteristics (green symbols).

KEY TO SYMBOLS

Red symbols indicate internal characteristics.

Green symbols indicate external characteristics.

Sample Image Used



COLOR

D E F G H I J Faint Very Light Light

CLARITY

FL IF VS¹⁻² VS¹⁻² SI¹⁻² I¹⁻³

Flawless Internally Flawless Very Very Slightly Included Very Slightly Included Slightly Included Included

ADDITIONAL GRADING INFORMATION

Polish

Symmetry

Fluorescence


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OVAL BRILLIANT

10.91 X 7.73 X 4.68 MM

Carat Weight

Color Grade

Clarity Grade

Table

Depth

Girdle

Medium to Slightly Thick (Faceted)

Culet

Polish

Symmetry

Fluorescence

Inscription(s)

2.51 CARATS

F

VS 1

60.5%


62%

Pointed

EXCELLENT

EXCELLENT

NONE

 LG756541577

Comments: The Laboratory Grown Diamond was created by Chemical Vapor Deposition (CVD) growth process. Type IIa

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